

Patent Assignment Abstract of Title

Total Assignments: 1
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Inventors: Min Ho Jung, Sung Eun Hong, Jae Chang Jung, Geun Su Lee, Ki Ho Baik

Title: Additive for photoresist composition for resist flow process

Assignment: 1
Reel/Frame: 012165/0914 **Received:** 09/20/2001 **Recorded:** 09/17/2001 **Mailed:** 11/21/2001 **Pages:** 3

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Exec Dt: 07/10/2001

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Search Results as of: 5/14/2003 8:44:07 A.M.

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L Number	Hits	Search Text	DB	Time stamp
1	5704	(430/270.1 430/905 430/910 552/552 526/281 528/298 568/369).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/14 11:43
2	8054	lithocholate deoxycholate androstane cholate	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/14 11:43
3	2214	((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/14 11:44
4	127	((430/270.1 430/905 430/910 552/552 526/281 528/298 568/369).CCLS.) AND (lithocholate deoxycholate androstane cholate)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/14 11:44
5	65	((430/270.1 430/905 430/910 552/552 526/281 528/298 568/369).CCLS.) AND (lithocholate deoxycholate androstane cholate)) AND (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/14 11:44
6	40	((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent))) and lithocholate	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/14 11:44
7	56	((lithocholate deoxycholate androstane cholate) and (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent))))) not (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))) and lithocholate)) (("5580694") or ("5786131") or ("2002044324") or ("6497987") or ("5641767") or ("6268106") or ("6180316")).PN.) wo-200244324-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/14 11:45
8	56	((lithocholate deoxycholate androstane cholate) and (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent))))) not (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))) and lithocholate)) (("5580694") or ("5786131") or ("2002044324") or ("6497987") or ("5641767") or ("6268106") or ("6180316")).PN.) wo-200244324-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/14 11:46

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9	0	((((430/270.1 430/905 430/910 552/552 526/281 528/298 568/369).CCLS.) AND (lithocholate deoxycholate androstan e cholate)) AND (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))) NOT (((((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))) and lithocholate) (((lithocholate deoxycholate androstan e cholate) and (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))) not (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))) and lithocholate)) (((5580694") or ("5786131") or ("2002044324") or ("6497987") or ("5641767") or ("6268106") or ("6180316")).PN.) wo-200244324-\$ did.) (((lithocholate deoxycholate androstan e cholate) and (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))) not (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))) and lithocholate)) (((5580694") or ("5786131") or ("2002044324") or ("6497987") or ("5641767") or ("6268106") or ("6180316")).PN.) wo-200244324-\$ did.))	USPAT; US-PPGPUB; EPO; JPO; DERWENT	2003/05/14 11:46
	2	("20020022197").PN.	USPAT; US-PPGPUB; EPO; JPO; DERWENT	2003/05/13 15:35
	3069423	(polymer resin binder resist photoresist)	USPAT; US-PPGPUB; EPO; JPO; DERWENT	2003/05/13 13:05
	13754	\$5acid near generat\$3	USPAT; US-PPGPUB; EPO; JPO; DERWENT	2003/05/13 13:06
	476884	additive	USPAT; US-PPGPUB; EPO; JPO; DERWENT	2003/05/13 13:06
	996705	solvent (organic adj solvent)	USPAT; US-PPGPUB; EPO; JPO; DERWENT	2003/05/13 13:06
	2232	((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))	USPAT; US-PPGPUB; EPO; JPO; DERWENT	2003/05/14 11:44
	104	lithocholate	USPAT; US-PPGPUB; EPO; JPO; DERWENT	2003/05/13 14:22
	39	((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent))) and lithocholate	USPAT; US-PPGPUB; EPO; JPO; DERWENT	2003/05/14 11:43
	0	\$5cholate androstan e	USPAT; US-PPGPUB; EPO; JPO; DERWENT	2003/05/13 15:07

	0	\$5cholate	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 15:04
	0	androstane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 15:07
	8054	lithocholate deoxycholate androstane cholate	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/14 11:43
	2214	((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 15:37
	77	(lithocholate deoxycholate androstane cholate) and (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 15:38
	40	((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent))) and lithocholate	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/14 11:44
	38	((lithocholate deoxycholate androstane cholate) and (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))) not (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent))) and lithocholate)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 15:54
	14	(("5580694") or ("5786131") or ("2002044324") or ("6497987") or ("5641767") or ("6268106") or ("6180316")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 15:59
	1	wo-200244324-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 16:00
	53	((lithocholate deoxycholate androstane cholate) and (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent)))) not (((polymer resin binder resist photoresist)) and (\$5acid near generat\$3) and additive and (solvent (organic adj solvent))) and lithocholate) ((("5580694") or ("5786131") or ("2002044324") or ("6497987") or ("5641767") or ("6268106") or ("6180316")).PN.) wo-200244324-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/14 11:45
	1208	JUNG-MIIN JUNG-MIN JUNG-MING JUNG-MINO-HO JUNG-MIN-HO JUNG-M-H HONG-SUNG HONG-SUNG-EUN JUNG-JAE-CHANG JUNG-JAE-CHEUN LEE-GEUN-SOO LEE-GEUN-SU BAIK-K BAIK-KI-HO BAIK-K-H (JUNG-MIIN JUNG-MIN JUNG-MING JUNG-MINO-HO JUNG-MIN-HO JUNG-M-H HONG-SUNG HONG-SUNG-EUN JUNG-JAE-CHANG JUNG-JAE-CHEUN LEE-GEUN-SOO LEE-GEUN-SU BAIK-K BAIK-KI-HO BAIK-K-H) and (lithocholate deoxycholate androstane cholate)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 17:47
	1	(photoresist adj composition) same (antireflective adj film)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 17:48
	6	(photoresist adj composition) same (antireflective adj film)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 17:52
	6	wo-9733198-\$.did. ep-789278-\$.did. ep-690348-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 17:51

-	1628	(photoresist adj composition) same coating	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 17:53
-	299	((photoresist adj composition) same coating) not (exposure irradiation)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/13 17:55
-	43	((photoresist adj composition) same coating) not (exposure irradiation)	USPAT	2003/05/13 18:24
-	109	428/\$.ccls. and (\$5resist adj composition)	USPAT	2003/05/13 18:29
-	2	("6416926").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/14 08:24
-	0	2000038391.URPN.	USPAT	2003/05/14 08:29
-	1	"6150069".PN.	USPAT	2003/05/14 08:30
-	6	6150069.URPN.	USPAT	2003/05/14 08:30
-	1	6391518.URPN.	USPAT	2003/05/14 08:37
-	13	("3370047" "4011386" "4106943" "4202955" "4491628" "4883740" "5087677" "5212043" "5252427" "5278214" "5585219" "6143466" "6150069").PN.	USPAT	2003/05/14 08:37